

“Biaxially aligned titanium nitride thin films deposited by reactive unbalanced magnetron sputtering”. Mahieu S, Ghekiere P, de Winter G, de Gryse R, Depla D, Van Tendeloo G, Lebedev OI, *Surface and coatings technology* **200**, 2764 (2006).
<http://doi.org/10.1016/j.surfcoat.2004.09.012>